

Title	Fe- and Ni-doped TiO <sub>2</sub> thin films grown on LaAlO <sub>3</sub> and SrTiO <sub>3</sub> substrates by laser ablation
Author(s)	Nguyen, Hoa Hong; Prellier, W.; Sakai, Joe; Hassini, Awatef
Citation	Applied Physics Letters, 84(15): 2850-2852
Issue Date	2004-04
Type	Journal Article
Text version	publisher
URL	<a href="http://hdl.handle.net/10119/3997">http://hdl.handle.net/10119/3997</a>
Rights	Copyright 2004 American Institute of Physics. This article may be downloaded for personal use only. Any other use requires prior permission of the author and the American Institute of Physics. The following article appeared in Nguyen Hoa Hong, W. Prellier, Joe Sakai, Awatef Hassini, Applied Physics Letters 84(15), 2850-2852 (2004) and may be found at <a href="http://link.aip.org/link/?apl/84/2850">http://link.aip.org/link/?apl/84/2850</a> .
Description	

# Fe- and Ni-doped TiO<sub>2</sub> thin films grown on LaAlO<sub>3</sub> and SrTiO<sub>3</sub> substrates by laser ablation

Nguyen Hoa Hong<sup>a)</sup>

Laboratoire LEMA, UMR 6157 CNRS/CEA, Université F. Rabelais, Parc de Grandmont, 37200 Tours, France

W. Prellier

Laboratoire CRISMAT, CNRS UMR 6508, ENSICAEN, 6 Bd Maréchal Juin, 14050 Caen, France

Joe Sakai

School of Materials Science, JAIST, Asahidai 1-1, Tatsunokuchi-machi, Ishikawa 923-1292, Japan

Awatef Hassini

Laboratoire LEMA, UMR 6157 CNRS/CEA, Université F. Rabelais, Parc de Grandmont, 37200 Tours, France

(Received 22 September 2003; accepted 5 February 2004)

Room temperature ferromagnetic Fe- and Ni-doped TiO<sub>2</sub> thin films were grown by the laser ablation on both LaAlO<sub>3</sub> and SrTiO<sub>3</sub> substrates. Most of the films are pure anatase, and only the films of Ni content of 3.6% and 4.6% are rutile. Films on LaAlO<sub>3</sub> substrates are more crystallized than films on SrTiO<sub>3</sub> substrates resulting from the lattice mismatch. Our magnetic measurements also suggest that the ferromagnetism in Fe/Ni:TiO<sub>2</sub> films is not due to Fe/Ni segregations but due to Fe/Ni:TiO<sub>2</sub> matrices. © 2004 American Institute of Physics. [DOI: 10.1063/1.1695103]

After the prediction of room temperature ferromagnetism (FM) for Mn-doped ZnO of Dietl *et al.*,<sup>1</sup> there has been a lot of research following this trend. According to theory,<sup>2</sup> doping V, Fe, Ni, Co, and Cr might introduce magnetism into a semiconducting oxide host. Since the discovery of Matsumoto *et al.*,<sup>3</sup> Co:TiO<sub>2</sub> thin films have attracted many research groups due to their exhibition of very high Curie temperature ( $T_C$ ). While Co-doped ZnO or TiO<sub>2</sub> thin films have been fabricated by various techniques,<sup>4-7</sup> not much work has been done on Fe/Ni-doped ZnO or TiO<sub>2</sub> films. So far, no evidence of FM has been reported for Fe:ZnO films,<sup>8,9</sup> and for Ni:ZnO films, FM was found only at 2 K.<sup>10</sup> As regards to TiO<sub>2</sub> host, there have been very few reports on Fe and Ni dopings. Bally *et al.* found no FM in Fe:TiO<sub>2</sub> thin films,<sup>11</sup> while Wang *et al.* recently obtained high  $T_C$  ferromagnetic Fe:TiO<sub>2</sub> films only on sapphire substrates.<sup>12</sup> In this letter, we report about high  $T_C$  ferromagnetic Fe/Ni:TiO<sub>2</sub> thin films grown by laser ablation on both LaAlO<sub>3</sub> (LAO) and SrTiO<sub>3</sub> (STO) substrates.

Fe/Ni:TiO<sub>2</sub> targets with the dopant concentration of 8% were synthesized by a sol-gel method. 2700-Å-thick-Fe/Ni:TiO<sub>2</sub> films were deposited by the pulsed laser deposition (PLD) technique (248 nm KrF excimer laser, pulses of 5 Hz) on (001) LAO and (001) STO substrates. The oxygen partial pressure ( $P_{O_2}$ ) was  $10^{-6}$  Torr, and the energy density was 1, 1.5, 3, or 5 J/cm<sup>2</sup>. The substrate temperature was 700 °C. After deposition, all films were cooled down to room temperature under a  $P_{O_2}$  of 20 mTorr.

Fe-doped films are pink and Ni-doped films are transparent, and they are very shiny indicating very smooth surfaces. From the RBS data, the Fe content was estimated to be 8.1% and 12.6% for the films grown under the fluence of 1.5 and 3 J/cm<sup>2</sup>, while the Ni content was 3.6%, 4.3%, 4.6%, and 5.2%

for the films grown under the fluence of 1, 1.5, 3, and 5 J/cm<sup>2</sup>, respectively.

XRD showed that all of our films are well epitaxial (from  $\Phi$  scan not shown) and highly *c*-axis oriented. While only Ni:TiO<sub>2</sub> films of Ni=3.6% and 4.6% deposited on LAO show rutile structure [Fig. 3(c)], all other Fe/Ni:TiO<sub>2</sub> films grown on both types of substrates are single phased anatase [Figs. 1, 2(a), and 2(b)]. We did not see any trace of impurities, at least from the XRD data. The diffraction peaks which are more intense and sharper for films on LAO than those of films on STO indicate a better crystallinity on LAO. As observed previously, this is a result of the smaller lattice

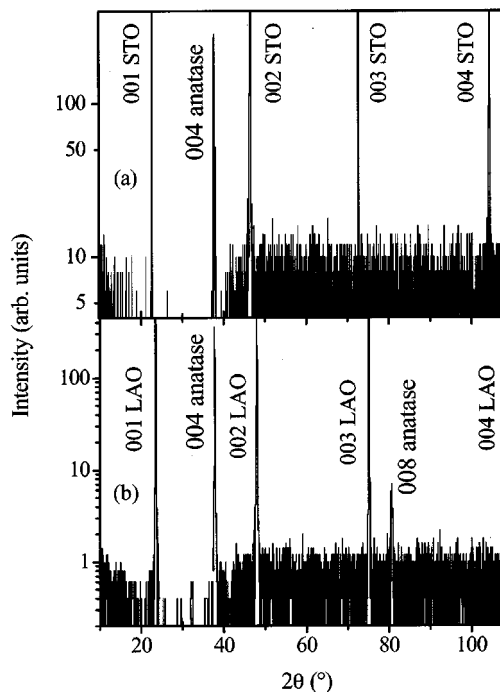


FIG. 1. XRD for a Ti<sub>0.919</sub>Fe<sub>0.081</sub>O<sub>2</sub> film deposited on (a) STO and (b) LAO.

<sup>a)</sup>Electronic mail: hoahong@delphi.phys.univ-tours.fr

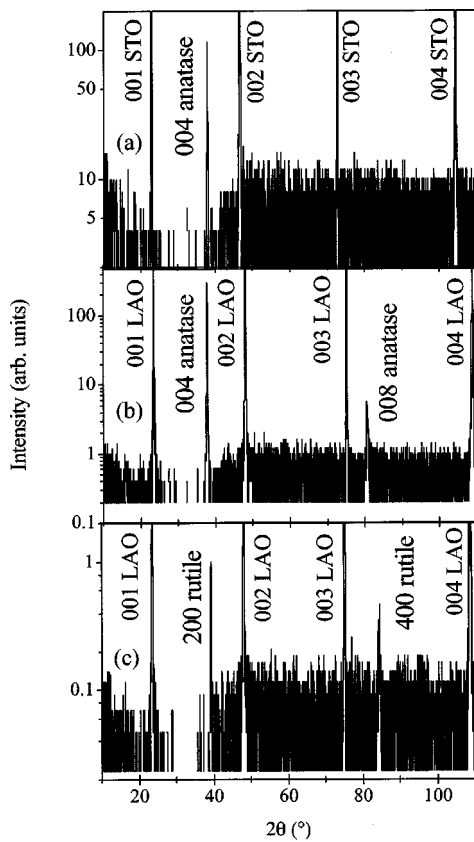


FIG. 2. XRD for  $\text{NiTiO}_2$  films: (a)  $\text{Ti}_{0.957}\text{Ni}_{0.043}\text{O}_2/\text{STO}$ , (b)  $\text{Ti}_{0.957}\text{Ni}_{0.043}\text{O}_2/\text{LAO}$ , and (c)  $\text{Ti}_{0.954}\text{Ni}_{0.046}\text{O}_2/\text{LAO}$ . Note that for  $\text{Ti}_{0.954}\text{Ni}_{0.046}\text{O}_2$ , the film exhibits a rutile structure.

mismatch.<sup>13</sup> By comparing Fig. 2(a) and Fig. 2(b), Fig. 3(a) and Fig. 3(b), we can see that the 008 anatase diffraction peak (at  $2\theta=80^\circ$ ), which was observed in films on LAO, is not clearly seen in films on STO. This might be due to a difference in oxygen vacancies which may vary from one substrate to another. At some critical point, it might be claimed to the formation of Magnéli shear planes.<sup>12</sup> However, the formation of that plane is more common in the case of rutile  $\text{TiO}_2$  crystallizing in a tetragonal lattice, but the films that we are discussing are anatase. Thus, it seems that the lack of that peak is more reasonable to be caused by oxygen. The out-of-plane lattice parameters of films with various contents of Fe/Ni on STO/LAO are summarized in Table I. One can see that for STO substrates, the lattice parameter basically increases upon Fe doping (compared to the nondoped  $\text{TiO}_2$  parameter as of  $9.513 \text{ \AA}$ ),<sup>14</sup> but above 8.1% it remains almost constant versus Fe content, while the lattice parameter increases upon Ni doping as Ni content is up to 4.3%, and then decreases a bit. This suggested that Fe/Ni was really substituted for Ti in  $\text{TiO}_2$  and the doping does not deteriorate the anatase structure. On LAO substrates, the situation is more complicated. While in the Fe doping case, the lattice parameter does not change much versus the Fe content and the structure remains thoroughly as anatase, in the Ni doping case, as the Ni content is 3.6% or 4.6% [Fig. 2(c)], the films were crystallized in a rutile-type structure with a  $c$ -axis length of 4.597 or 4.588  $\text{ \AA}$  (in comparison to 4.595  $\text{ \AA}$  of nondoped  $\text{TiO}_2$  rutile).<sup>15</sup> So far, no rutile Co/Fe/Ni: $\text{TiO}_2$  thin film has been obtained on either LAO or STO substrates. This case is rare and interesting, since this

TABLE I. Evolution of the out-of-plane lattice parameters for various films with different contents of Fe and Ni on two types of substrates. Diffraction peaks correspond to an anatase-type phase except for the films of 4.6% and 5.13% of Ni on LAO (marked by an asterisk) where the films crystallized in a rutile-type structure (anatase  $\text{TiO}_2$  has  $c=9.513 \text{ \AA}$  and rutile has  $a=4.595 \text{ \AA}$ ).

Dopant	Content	Substrate	
		SrTiO <sub>3</sub> (Å)	LaAlO <sub>3</sub>
Fe	8.1%	9.532	9.512 Å
	12.6%	9.536	9.516 Å
Ni	3.6%	9.531	4.597 Å (*)
	4.3%	9.536	9.516 Å
	4.6%	9.512	4.588 Å (*)
	5.2%	9.522	9.512 Å

phase is very thermodynamically stable at high temperatures. Reference 11 reported that the doping might induce a structural transition from anatase to rutile above some critical dopant concentration. However, in our case, because all films with various Ni contents on STO are anatase, and the films of Ni=4.3% and 5.2% grown on LAO are anatase as well, even though the films of Ni=3.6% and 4.6% on LAO are rutile, it is not likely that there is any critical point for a structural transition. The assumption in a recent study on Er: $\text{TiO}_2$  films which suggested that the  $P_{\text{O}_2}$  during deposition would define a doped  $\text{TiO}_2$  films to be anatase or rutile<sup>16</sup> also cannot explain our case, since all films were deposited under the same  $P_{\text{O}_2}$ . By comparing the out-of-plane lattice parameters of the films grown on LAO or STO, we also found that the  $c$ -axis lattice parameters are smaller for films on LAO compared to those on STO (for the same dopant content). This is quite opposite to the previous reports about substrate effects in oxide thin films<sup>17</sup> therefore, it implies the presence of oxygen vacancies in our films.

The  $M(T)$  curves taken at 0.2 T for Fe: $\text{TiO}_2$  films are shown in Fig. 3(a). Except for the film of Fe=12.6% on STO which shows a weak FM below 50 K, and a superparamagnetism for higher temperatures, all other films are ferromagnetic with  $T_C$  higher than 400 K. Figure 3(b) shows the  $M(H)$  curve taken at 300 K for the film of Fe=8.1% on LAO. The observed hysteresis loop shows that the film is ferromagnetic at room temperature. In fact, a large saturation magnetization ( $M_s$ ) was expected to obtain in Fe: $\text{TiO}_2$  films but the maximum  $M_s$  in our films is found to be only 0.14  $\mu_B$  per Fe atom. While only the film of Ni=4.3% is superparamagnetic, all other films on LAO are room temperature ferromagnetic with the  $M_s$  being 2.7, 0.3, and 1.3  $\mu_B$  for Ni=3.6%, 4.6%, and 5.2%, respectively. As seen in Fig. 4(a), the magnetization starts to fall near 400 K, therefore, the  $T_C$  is estimated to be just a bit higher. From the magnetization data in Fig. 4 and parameters shown in Table I, one can see that the films of Ni content of 3.6% and 5.2% on LAO whose parameters are closest to the nondoped  $\text{TiO}_2$  parameters (rutile and anatase) have the largest  $M_s$  [referring Fig. 4(a)]. It seems that in these cases, Ni was well substituted for Ti in the  $\text{TiO}_2$  host, and we obtained a solid solution. By contrast, Ni: $\text{TiO}_2$ /STO films showed a weaker FM, either with a smaller  $M_s$  (as Ni=3.6% and 5.2%) or low  $T_C$  (as Ni=4.3% and 4.6%) [Fig. 4(b)].

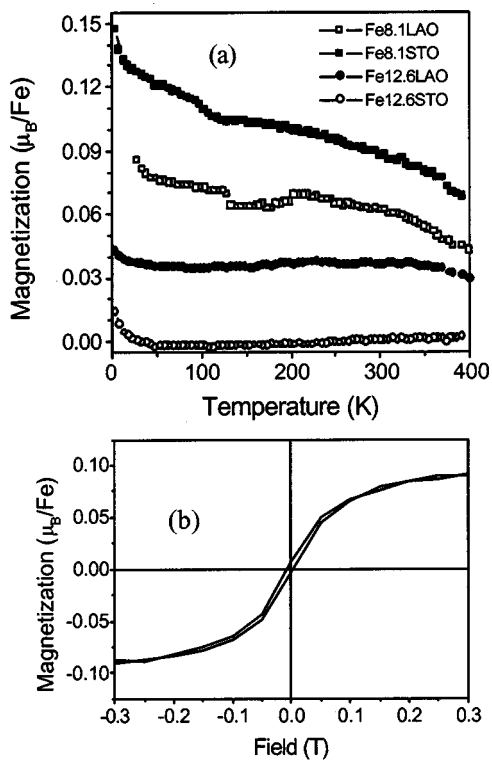


FIG. 3. Magnetization of Fe:TiO<sub>2</sub> films (a) vs temperature at 0.2 T for various Fe contents on both substrates and (b) vs magnetic field at 300 K for the film of Fe=8.1% on LAO. In each case, a bare substrate with the same size as of the film (0.5 cm×0.5 cm) was measured at the same field or temperature in order to subtract directly.

Among all of the transition metal-doped TiO<sub>2</sub> films on LAO we have made, Ni-doped films have the largest  $M_s$  (larger than that of Fe-doped films mentioned earlier and also larger than  $M_s$  of Co:TiO<sub>2</sub> films which were fabricated under the same condition<sup>7</sup>). This is unexpected because Ni metal has the lowest  $T_C$  and the smallest  $M_s$  among Fe, Co, and Ni, as regards to magnetism of each individual element. This is an additional indirect evidence to show that the FM does not come from Fe/Ni metal or clusters, but from the Fe/Ni:TiO<sub>2</sub> matrices, besides the fact that our Fe/Ni-doped films do not have the  $T_C$  as high as 1043 K (if it is from Fe metal) or 627 K (if it is from Ni metal). Note that in our films, FM is not caused by Fe or Ni particles because if it happened,  $M_s$  must be 2.22  $\mu_B$  for the Fe case and 0.6  $\mu_B$  for Ni case, but the  $M_s$  of our films is much smaller in Fe case (as 0.14  $\mu_B/\text{Fe}$ ) and much larger in Ni case (as 2.7  $\mu_B$ ). The XRD pictures which show no trace of Fe and Ni metal as well as of iron and nickel oxides, along with the smooth surface observed by SEM, likely rule out the possibility of having Fe/Ni clusters.

We obtained pure anatase Fe:TiO<sub>2</sub> films and anatase or rutile Ni:TiO<sub>2</sub> films grown on both LAO and STO substrates. While most of Fe:TiO<sub>2</sub> films show FM above room temperature with a rather modest  $M_s$ , the only Ni:TiO<sub>2</sub> films on LAO whose lattice parameters are closest to that of non-doped TiO<sub>2</sub> are strongly ferromagnetic with a large  $M_s$ . The pure rutile structure in films grown on LAO is rather special, because so far, transition metal-doped TiO<sub>2</sub> films on either STO or LAO substrates are often anatase. All films are single

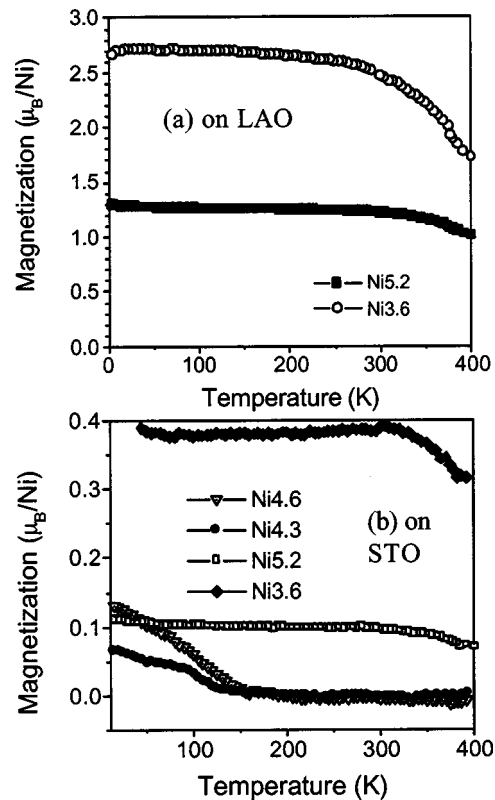


FIG. 4. Magnetization vs temperature at 0.2 T for (a) Ni:TiO<sub>2</sub> films with Ni content of 3.6% and 5.2% on LAO and (b) Ni:TiO<sub>2</sub> films with various Ni contents on STO.

phase and highly crystallized. Due to the smaller lattice mismatch in the case of LAO, films on LAO are more oriented and crystallized than films on STO.

- <sup>1</sup>T. Dietl, H. Ohno, F. Matsukura, J. Cibert, and D. Ferrand, *Science* **287**, 1019 (2000).
- <sup>2</sup>K. Sato and H. Katayama-Yoshida, *Jpn. J. Appl. Phys., Part 2* **39**, L555 (2000).
- <sup>3</sup>Y. Matsumoto, M. Murakami, T. Shono, T. Hasegawa, T. Fukumura, M. Kawasaki, P. Ahmet, T. Chikyow, S. Koshihara, and H. Koinuma, *Science* **291**, 854 (2001).
- <sup>4</sup>Y. Matsumoto, R. Takahashi, M. Murakami, T. Koida, X.-J. Fan, T. Hasegawa, T. Fukumura, M. Kawasaki, S. Koshihara, and H. Koinuma, *Jpn. J. Appl. Phys., Part 1* **40**, 1204 (2001).
- <sup>5</sup>S. A. Chamber, S. Thevuthasan, R. F. Farrow, R. F. Marks, J. U. Thiele, L. Folks, M. G. Samant, A. J. Kellock, N. Ruzycski, D. L. Ederer, and U. Diebold, *Appl. Phys. Lett.* **79**, 3467 (2001).
- <sup>6</sup>W. Prellier, A. Fouchet, B. Mercey, Ch. Simon, and B. Raveau, *Appl. Phys. Lett.* **82**, 3490 (2003).
- <sup>7</sup>N. H. Hong, J. Sakai, W. Prellier, and A. Hassini, *Appl. Phys. Lett.* **83**, 3129 (2003).
- <sup>8</sup>Z. Jin, M. Murakami, T. Fukumura, Y. Matsumoto, A. Ohtomo, M. Kawasaki, and H. Koinuma, *J. Cryst. Growth* **55**, 214 (2000).
- <sup>9</sup>Z. Jin, T. Fukumura, M. Kawasaki, K. Ando, H. Saito, T. Sekiguchi, Y. Z. Yoo, M. Mukarami, Y. Matsumoto, T. Hasegawa, and H. Koinuma, *Appl. Phys. Lett.* **78**, 3824 (2001).
- <sup>10</sup>T. Wakano, N. Fujimura, Y. Morinaga, N. Abe, A. Ashida, and T. Ito, *Physica C* **10**, 260 (2001).
- <sup>11</sup>A. R. Bally, E. N. Korobeinikova, P. E. Schmid, F. Levi, and F. Bussy, *J. Phys. D* **31**, 1149 (1998).
- <sup>12</sup>Z. Wang, W. Wang, J. Tang, L. D. Tung, L. Spinu, and W. Zhou, *Appl. Phys. Lett.* **83**, 518 (2003).
- <sup>13</sup>N. H. Hong, J. Sakai, W. Prellier, and A. Hassini (unpublished).
- <sup>14</sup>Ref. ICSD Card No. 202242.
- <sup>15</sup>Ref. ICSD Card No. 082656.
- <sup>16</sup>M. Ishii, S. Komuro, and T. Morikawa, *J. Appl. Phys.* **94**, 3823 (2003).
- <sup>17</sup>W. Prellier, A. M. Haghiri-Gosnet, B. Mercey, Ph. Lecoeur, M. Hervieu, Ch. Simon, and B. Raveau, *Appl. Phys. Lett.* **77**, 1023 (2000).